Form PTO-1449

INFORMATION DISCLOSURE CITATION IN AN APPLICATION

(Use several sheets if necessary)

Docket Number (Optional)	Application Number
TSMC-[redacted]-079	09/579,542
Applicant: Cheng Chung Lin et al.	
Filing Date: 05/26/00	Group Art Unit: 1708

RECEIVED SEP 28 2001 GROUP 1700

U. S. PATENT DOCUMENTS

EXAMINER INITIAL	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
LV	5593741	1/14/97	Ikeda	427	579	8/28/95
LV	5514624	5/7/96	Morozumi	437	195	7/19/93
LV	5432129	7/11/95	Hodges	437	200	4/29/93
LV	4992306	2/12/91	Hochberg et al.	427	255.3	2/1/90

OIPE AUG 07 2001 PATENT & TRADEMARK OFFICE JC82

FOREIGN PATENT DOCUMENTS

	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	Translation YES	Translation NO

OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)

LV	The Applied Materials website for 3/4/00 - gives reference to Black Diamond.

EXAMINER	DATE CONSIDERED
LAN VINH	9/17/2001

EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP § 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to the applicant.